

Plasma Modified MoS₂ Nanoflakes for Surface Enhanced Raman Scattering

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Molybdenum disulfide (MoS₂), a new type of two dimensional (2D) layered transition metal dichalcogenides with its unique electronic, optical, and mechanical properties, has been investigated and applied widely in transistors,^[1–3] gas sensors,^[4,5] lithium ion batteries,^[6–8] spintronics,^[9,10] hydrogen production,^[11,12] and dry lubricant, etc.^[13] Furthermore, the recent works reported that when MoS₂ exposed to triethylamine, it can be used effectively as a chemical sensor and exhibit a highly selective reactivity to a wide range of analytes due to the charge redistribution induced by the perturbations on the MoS₂ surface.^[14] Thus, surface modification leads to the strong interaction between MoS₂ and detected molecules. Some experiments have also been reported to tune the activity of substrate for surface enhanced Raman scattering (SERS), such as nitrogen doping enhanced molecule sensing,^[15] UV/Ozone oxidized treatment with an improved detection sensitivity,^[16] and fluorinate function

on graphene oxide by CF₄ plasma to increase molecule detection.^[17] In this work, we observe an improved Raman enhancement of Rhodamine 6G (R6G) molecules deposited on oxygen-plasma treated MoS₂ (OT-MoS₂) and argon-plasma treated MoS₂ (AT-MoS₂) nanoflakes. Compared with the intensity of Raman spectra of R6G on pristine MoS₂ (P-MoS₂) nanoflakes, it is found that the Raman intensities of R6G molecules on both oxygen and argon plasma treated MoS₂ (T-MoS₂) are enhanced more than one order. The introduction of defects in T-MoS₂ samples changes the local surface properties of MoS₂ nanoflakes, such as creating the local dipoles which give rise to the enhancement of Raman signals of R6G molecules and adsorbance of the oxygen in ambient air to dope holes in MoS₂, resulting in the enhanced charge transfer effect between R6G and MoS₂. Furthermore, the layer-dependent Raman enhancement (R6G) mechanism on MoS₂ nanoflakes is explained in detail by comparing the enhancement behaviors on both supported and suspended MoS₂ nanoflakes with different layer numbers.

High crystalline quality MoS₂ nanoflakes were mechanically exfoliated from commercial MoS₂ crystal (SPI Supplies), and then transferred to a p-type silicon wafer coated by a 285 nm thick silicon oxide (SiO₂) layer. The R6G deposited on P-MoS₂ sample does not show obvious Raman enhancement. In contrast, the R6G molecules deposited on T-MoS₂ present dramatically enhanced Raman intensities. The comparison of Raman intensities of R6G molecules that deposited on SiO₂/Si substrate, P-MoS₂, OT-MoS₂ and AT-MoS₂ is carefully analyzed. **Figure 1a** gives a schematic illustration of R6G molecules deposited on 1L P-MoS₂, OT-MoS₂ and AT-MoS₂, respectively. Figure 1b shows the Raman spectra of R6G molecules deposited on different substrates mentioned in Figure 1a. For identifying the fluorescence quenching effect of MoS₂, the Raman spectrum of R6G deposited directly on SiO₂/Si is also given. All the spectra were measured with a 532 nm laser (2.33 eV) and the laser power is below 0.5 mW to avoid laser induced local heating effects. From Figure 1b, it can be seen that the Raman signal of R6G on 1L P-MoS₂ sample can be almost ignored despite the fact that the fluorescence background is suppressed. On the other hand, the Raman signals of R6G molecules on both OT-MoS₂ and AT-MoS₂ samples are enhanced obviously with the further suppression of fluorescence background of R6G compared to that of R6G on P-MoS₂. According to the previous reports, structural disorder can usually introduce local dipoles leading to

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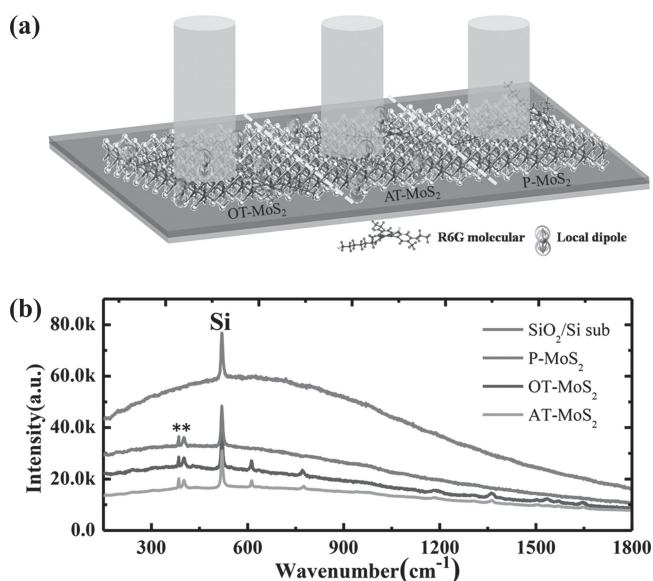


Figure 1. a) Schematic illustration of the R6G molecules on 1L P-MoS₂ and OT(AT)-MoS₂, respectively; b) Raman spectra of R6G molecules on SiO₂/Si substrate, 1L P-MoS₂ and OT(AT)-MoS₂. The Raman peaks originate from MoS₂ denoted by asterisks (*).

the improved SERS effect.^[15–17] As 1L MoS₂ is only ~0.65 nm thick, its structure is easily modified during plasma treatment (bombardment) process, thus the generated structural disorder induced local dipole in 1L MoS₂ should be the driven force for enhancing Raman signals of R6G molecules. Next, we will reveal the SERS mechanism by studying the surface properties of the plasma treated MoS₂ samples in detail.

Raman and photoluminescence (PL) spectra of P-MoS₂ and OT(AT)-MoS₂ are shown in **Figure 2**. From the Raman spectra, it can be seen obviously that the frequency difference between the two prominent Raman modes, E_{2g}¹ and A_{1g}¹, becomes larger for the treated samples by oxygen (argon) plasma. Eda et al. has observed similar effect on chemically exfoliated single layer MoS₂ nanoflakes.^[18] CVD grown MoS₂ nanoflakes also show a larger frequency difference between these two predominant peaks compared to that of the MoS₂ prepared by mechanical exfoliation.^[19,20] All of

them ascribed this phenomenon to the disordered surface structure of MoS₂ nanoflakes. Figure S1 (Supporting information) shows the atomic force microscopy (AFM) images of 1L P-MoS₂ and OT(AT)-MoS₂ nanoflakes. It can be seen that the surface of OT(AT)-MoS₂ samples becomes more rough compared to the surface of P-MoS₂ as shown by the height profiles in the inset of Figure S1, and the mean square roughness values for P-MoS₂, OT-MoS₂ and AT-MoS₂ are 0.171, 0.543 and 0.621 nm respectively. It indicates that the structural disorder is introduced into the MoS₂ nanoflakes during plasma treatment process.^[18,21] Furthermore, by investigating the variation of PL spectra of 1L P-MoS₂ and OT(AT)-MoS₂ nanoflakes shown in Figure 2b, it can be seen that the PL peak positions of both OT- and AT-MoS₂ show obvious blueshift compared to those of P-MoS₂. We propose that the blueshift of PL for T-MoS₂ is due to the band filling effect, which has been reported in disordered InN microcrystals,^[22] CdSe,^[23] and AlGaIn/GaN.^[24,25] As structure disorder in 2D material is normally a chemically unstable site, it is favorable to be adsorbed by oxygen in ambient air,^[26] and hence the adsorption of oxygen gives rise to the p-doping effect to MoS₂ nanoflakes because of the strong electronegativity of oxygen,^[27,28] which means that the adsorption of oxygen decreases the electron occupation level at around the top of valence band. As a consequence, the blueshift of PL peak is observed because the holes filling at the top of valence band provides the additional electronic transition pathways for increased PL emission energy. It is worth mentioning that once the OT(AT)-MoS₂ samples were put into the vacuum chamber (~1×10⁻² mbar), the in-situ measurement probed that the blueshifted PL peak of T-MoS₂ shows redshift, and the peak position recovers back to the position as similar as that of pristine MoS₂ sample. It indicates that the physically adsorbed O₂ is desorbed in vacuum environment. Interestingly, the PL peak position shows an obvious blueshift again once the samples re-exposed in ambient air (**Figure 3**). This vacuum experiment confirms that the oxygen in ambient air is favorable to be weakly adsorbed at defect sites of T-MoS₂, and it can be desorbed easily in vacuum.^[26]

To explore the interaction between the R6G molecules and both P-MoS₂ and T-MoS₂, we carried out the PL spectra

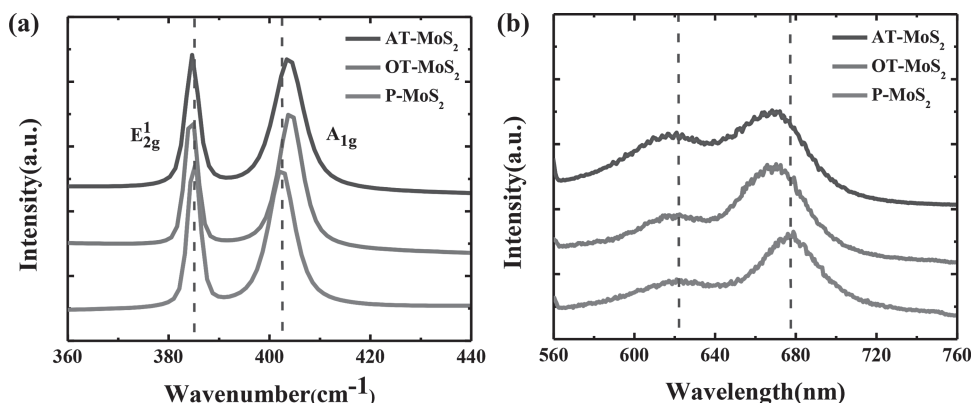


Figure 2. a) Raman spectra and b) PL spectra of 1L P-MoS₂ and OT(AT)-MoS₂. The blue dashed lines represent the Raman (a) and PL (b) peak positions of 1L P-MoS₂ samples, respectively.

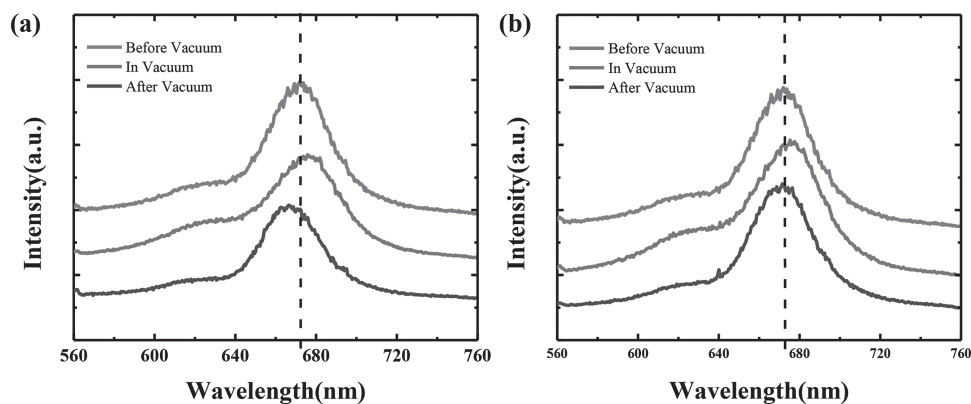


Figure 3. PL measurements for 1L (a) OT-MoS₂ and (b) AT-MoS₂ samples. The red lines represent the samples measured in ambient air before putting into the vacuum chamber; the green lines represent the samples measured in vacuum at 1×10^{-2} mbar; the blue lines represent the samples re-exposed to the ambient air after removing the vacuum.

study on these samples. It is worth noting that as the surface properties of AT-MoS₂ and OT-MoS₂ do not present obvious difference, thus we will only use OT-MoS₂ on behalf of T-MoS₂ in the following experiments. As shown in Figure S2, it is found that after the deposition of R6G molecules, the blueshifted PL peak position of OT-MoS₂ shows the redshift. One possible explanation to this phenomenon is the charge transfer effect. **Figure 4** gives the schematic illustration of the relative energy level between the ground and excited states of the R6G molecule and the electronic bands of MoS₂ at the low-energy regime. It can be seen that the top of valence band of MoS₂ is much lower compared to the excited state of R6G. Furthermore, as the adsorption of oxygen in OT-MoS₂ gives rise to the p-doping induced band filling effect, the top of valence band is filled by holes. Thus it fulfills the condition to accept the photoinduced electrons from the excited states of R6G, which would result in a blueshift of PL position

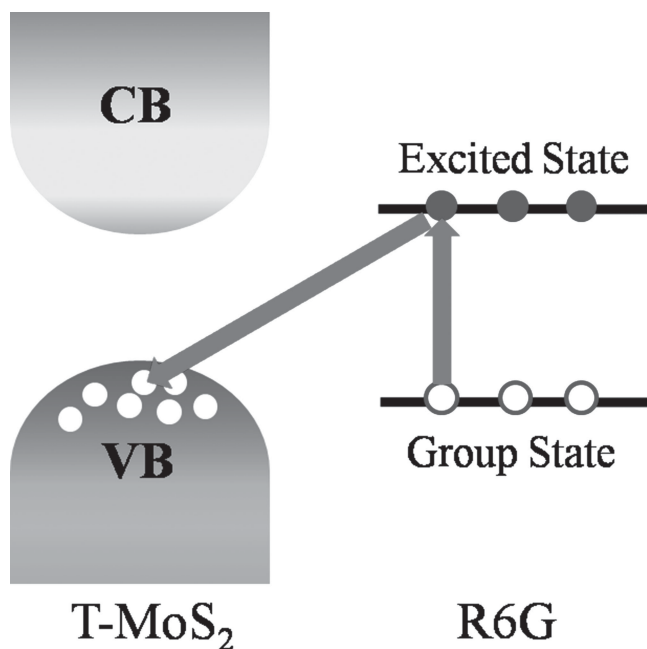


Figure 4. Schematic illustration of plasma enhanced photo-induced charge transfer between R6G molecular and T-MoS₂.

for OT-MoS₂. Furthermore, because the plasma bombardment induced removal of local atoms and the distortion of chemical bonds would break the original symmetry of MoS₂-crystal, the local dipoles can be formed on the surface of MoS₂ nanoflakes, as shown schematically in Figure 1a. The symmetry of R6G molecule system can be slightly changed by the interaction with local dipoles of T-MoS₂, resulting in the differences in the mode selection and finally enhancing the Raman signal of R6G.

In addition to the 1L MoS₂ nanoflakes discussed above, SERS effects of R6G molecules on MoS₂ nanoflakes with the different thicknesses were also investigated for better understanding the MoS₂-based SERS mechanism. **Figure 5a** shows the optical image of a typical MoS₂ sample, including single layer (1L), bilayer (2L), trilayer (3L), multilayer (ML, where $5 < M < 10$) and bulk. The corresponding AFM image and its height profile are shown in Figure 5b to identify the layer numbers of MoS₂ nanoflakes.^[29] The thicknesses were further confirmed by the Raman spectra (Figure 5c) in terms of the frequency difference between E_{2g}¹ and A_{1g} modes, which is consistent to the reported values.^[30,31] Figure 5d shows the Raman signals of R6G molecules deposited on OT-MoS₂ samples with the different thicknesses. Obviously, the Raman intensities of the R6G molecules are inversely proportional to the layer numbers of OT-MoS₂ nanoflakes as shown in Figure 5d. It is worth noting that the Raman signals of R6G molecules on bulk MoS₂ is very weak and it is almost invisible. Three possible factors may explain this thickness dependent Raman enhancement: (1) the layer dependent surface potential induced by the p-doping effect from SiO₂/Si substrate gives rise to the layer dependent SERS effect, which is just like the layer dependent SERS effect on different layered graphene samples.^[32,33] (2) 2D material with more number of layers is more structurally stable against the electron/ion bombardment, resulting in generation of less amount of structural disorder. (3) The bandgap of MoS₂ depends on the number of layers, which also affect the band alignment and further has an effect on the charge transfer proposed in the model shown in Figure 4.^[34,35] To find out the dominant factors, we specifically investigate the Raman spectra of R6G molecules on suspended OT-MoS₂ nanoflakes to examine whether this

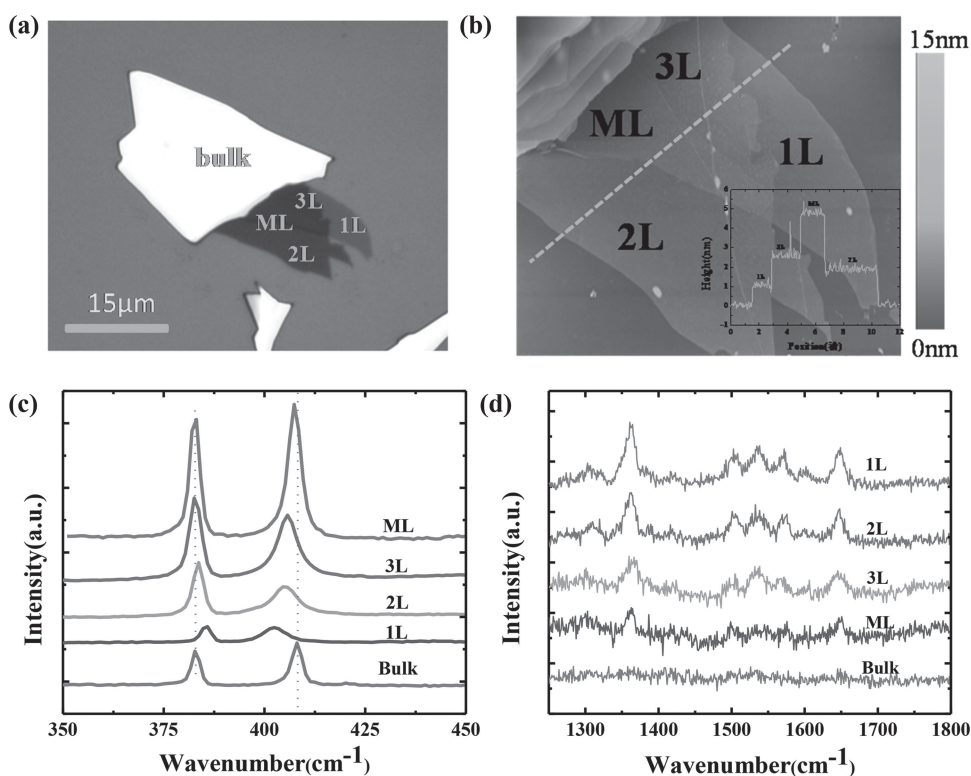


Figure 5. a) Optical image of a typical MoS₂ nanoflake deposited on SiO₂/Si. b) AFM image of MoS₂ nanoflake and its corresponding height profile. c) Raman spectra of OT-MoS₂ nanoflake, including 1L, 2L, 3L, ML and bulk. d) Raman spectra of R6G molecules on OT-MoS₂ samples with different thickness (baseline is subtracted in each spectrum).

layer-dependent enhancement effect in MoS₂ nanoflakes is related to the SiO₂/Si substrate (the proposed first factor). As shown in **Figure 6**, the 2L, 4L, ML, and bulk OT-MoS₂ samples are analyzed for studying the overall trend on the layer-dependent SERS effect. It is found that the trend of layer-dependent SERS effect for suspended OT-MoS₂ nanoflakes (Figure 6b) is similar as that for SiO₂/Si substrate supported OT-MoS₂ nanoflakes (Figure 5d), which indicates that the OT-MoS₂-based layer-dependent Raman enhancement for R6G is not caused by SiO₂/Si-substrate induced different surface potentials among different layered MoS₂ samples. Therefore, we propose that the decreased Raman enhancement factor with increasing thickness of OT-MoS₂ is mainly due to the rest two proposed factors, which are the less amount of structural disorder created (corresponding

to the less amount of local dipoles introduced) in thicker MoS₂ nanoflakes, as well as the different band alignment. While Raman spectra of P-MoS₂ and OT(AT)-MoS₂ nanoflakes shown in Figure S3a (2L) and S3c (3L) also support this conclusion. Combined with the Raman spectra of 1L P-MoS₂ and OT(AT)-MoS₂ shown in Figure 2a, it is clearly seen that the plasma treatment induced frequency variation for both E_{1g} and A_{1g} modes of MoS₂ decreases with increasing number of layers. Furthermore, comparing the PL peak position between P-MoS₂ and OT(AT)-MoS₂ in 1L (Figure 2b), 2L (Figure S3b) and 3L (Figure S3d), it is clearly seen that the PL blueshift effect of OT(AT)-MoS₂ decreases with increasing the thickness. Thus, both the Raman and PL results give evidence that under same plasma treatment condition, the structural disorders decreases with increasing

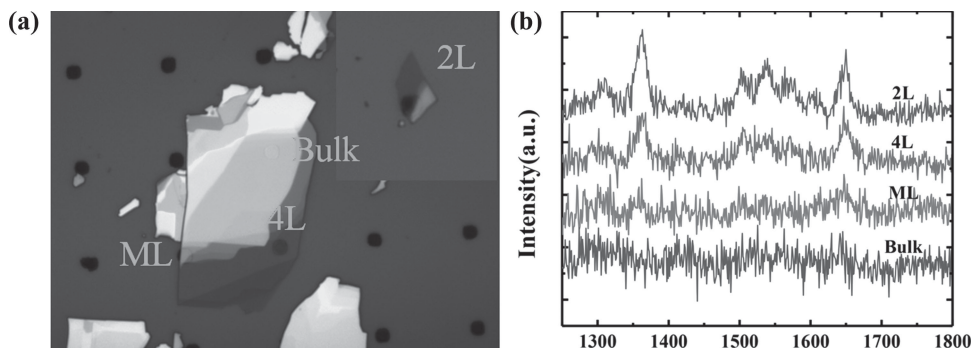


Figure 6. a) Optical images of suspended MoS₂ with different thicknesses (4L, ML and bulk), and the inserted image is suspended 2L MoS₂. b) Raman spectra of R6G on suspended OT-MoS₂ nanoflakes with different thickness (baseline is subtracted in each spectrum).

the thickness of MoS₂ nanoflakes.^[18–20] Therefore, the less amount of structural disorder introduced in relatively thicker MoS₂ nanoflake gives rise to the less amount of induced local dipoles, and hence the overall SERS effect becomes weaker.

Plasma treated MoS₂ nanoflakes for surface enhanced Raman scattering of R6G molecule is reported. By systematically studying the Raman and PL spectra of both P-MoS₂ and OT(AT)-MoS₂ samples, it is proved that the structural disorders are created by the plasma bombardment process, resulting in the generation of local dipoles and adsorption of oxygen in ambient air. The adsorption of oxygen decreases the electron occupation level at the top of valence band of MoS₂, and hence it enhances the photoinduced charge transfer between R6G and MoS₂, as a consequence, the fluorescence of R6G is dramatically suppressed. While the generation of the local dipoles enhances the Raman signals of R6G due to the change of symmetry. Furthermore, both SiO₂/Si-supported and suspended T-MoS₂ samples show similar layer-dependent Raman enhancement trend, indicating that Raman enhancement factor has no relationship with the SiO₂/Si substrate induced surface potential, but it is determined by the amount of structural disorder generated during plasma treatment. The investigation of the interaction between MoS₂ (both P-MoS₂ and OT(AT)-MoS₂) and organic molecules through the SERS effect paves a new way for the potential practical applications, such as using OT(AT)-MoS₂ nanoflakes for molecule detection and biological detection.

Experimental Section

In our experiments, MoS₂ nanoflakes were exfoliated by the scotch tape from a nature MoS₂ crystal (SPI Supplies). The prepared samples treated by oxygen (argon) plasma with a constant oxygen (argon) flow maintained at 80 sccm for 5 seconds, and then the samples were soaked in 10^{−6} mol/L R6G molecules solution for 2 hours. Another group of pristine MoS₂ nanoflakes was taken for reference. The holes on the surface of SiO₂/Si with diameter of ~3 μm and the depth of ~500 nm for measuring the suspended MoS₂ samples were etched by the photolithography method. The Raman spectra were excited by a 532 nm laser line and conducted using Renishaw Raman Microscopy configured with a charge coupled device array detector. The power of the excitation laser was kept below 0.5 mW. The Raman signals were collected by a Leica 100 × objective lens (NA = 0.85) and dispersed by 2400 line mm^{−1} gratings with frequency resolution of ~0.8 cm^{−1}. The PL measurement was performed on a WITTE CRM200 Raman system using a 532 nm laser as the excitation source with 150 line mm^{−1} grating.

Supporting Information

Supporting Information is available from the Wiley Online Library or from the author.

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